# **Record of Letter Ballot Review by TC Chapter for Procedural Review**

Region/Locale: Europe Global Technical Committee: Compound Semiconductor Materials TC Chapter Cochairs: Arnd Weber (SiCrystal) Standards Staff: Kevin Nguyen

	Scheduled in Background Statement	Actual
Date	TBD	April 29, 2021
Location	TBD	OVTCCM
Reason for Change of Date and/or Location (if changed)	COVID-19	

Note: See *Regulations* ¶ 9.5 Exceptions for allowable reason to change.

# I. Document Number and Title

Document Number 6615	<b>Document Title</b> REVISION OF SEMI M55-0817, SPECIFICATION FOR POLISHED MONOCRYSTALLINE SILICON CARBIDE
	WAFERS

# II. Tally

Standards staff to fill in.

#### Voting Tally: As-cast tally after close of voting period

Note: A minimum of 60% of the Voting Interests that have TC Members within the global technical committee that issued the Letter Ballot must return Votes. (*Regulations* ¶ 9.6.2.1.1)

Voting Tally:

Voting Interest:	<b>Returned Votes</b>		Distribution		Return Rate	
Letter Ballot	71	] ÷	95	=	74.7%	≥60%
Intercommittee Ballot	42					
Voting Interest Reject(s)	0	1	Total	Vote	rs with Rejects	0
Voting Interest Accept(s)	60	]				

Note: See Regulations § 3.2.1 for definition of Voting Interest.

# **III. Rejects**

None

# **IV. Other Technical Issues**

None

# **V.** Comments

V- (i) Voters' Comments Commenter 1 (Toshimasa Yamamoto/DENSO) - Comment 1

Com	*TF/TC Chapter to fill in section/paragraph #, if necessary.									
ment	In Fig A2 -5, the "Lasermark" and "[11-00] Direction" characters immediately above the primary flat overlap and are therefore be difficult to read, so it should be moved.									
	The TC Chapter agreed to do one of the following actions.									
	*No	motion is	requ	lired in this step.						
		Already a	ddres	sed by Commenter #, Comment #						
tion		No further	· actio	on was taken by the TC Chapter.						
ſ		Refer to the	ne TF	for more consideration.						
		New Busi	ness							
	х	Editorial C	Chang	ge						
		Options		Case 1: No vote in this section:						
		for editorial		To be included and voted on as a group in § VI. Editorial Changes Other than Those Voted on in § V.						
		change		Case 2: Voted in this section:						
		(check one)	х	Original section number and at least one full sentence are required in "FROM" and "TO" fields.						



Commenter 1	(Toshimasa	Yamamoto/DENSO	- Comment 2
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*TE/TC	Chapter to fill in section	/naragranh #	if necessa	arv	
		/paragraph #	, 11 11000336	ary.	
The "Tl Table A	hickness "and" Edge Pro A1 -9 are in a different o	ofile Coordin order and <mark>sho</mark>	nate " optio <mark>uld be unif</mark>	ons in the p fied if poss	13 Table A1 -8 and p 14 bible.
Table /	A1-8 Dimensional and Toleran	ce Characteristic	cs of 150-mm	Silicon Carbi	de Wafers
Ontion 1	Thickness	350	±25	μm	Only for high power applications (HP)
option 1	Edge Profile Coordinate Cy (see Table A1-5)	116		μm	T/3 Template
Option 2	Thickness	500	±25	μm	Only for high power applications (HP) and high frequency applications (HF)
	Edge Profile Coordinate Cy (see Table A1-5)	125		μm	T/4 Template
Table /	A1-9 Dimensional and Toleran	ce Characteristic	cs of 200-mm	Silicon Carbi	de Wafers
Change	r from				· · · · · · · · · · · · · · · · · · ·
	Thickness	<u>500</u>	±25	μm	
Option 1	<u> #1</u> GMLYMER (Warp)	<u>0</u>	<u>≤75</u>	μm	For high power applications and high frequency applications Customer and supplier have to agree on chuck-layout and gravity correction
-	Edge Profile Coordinate Cy (see Table A1-5)	125		μm	T/4 Template
	Thickness	<u>350</u>	±25	μm	
Option 2	#1 GMLYMER (Warp)	<u>0</u>	<u>≤85</u>	μm	For high power applications Customer and supplier have to agree on chuck-layout and gravity correction
	<u>Edge Profile Coordinate Cy</u> (see Table A1-5)	<u>116</u>		μm	T/3 Template
to					
	Thickness	<u>350</u>	<u>±25</u>	μm	_
(Option1	#1 GMLYMER (Warp)	<u>0</u>	<u>&lt;85</u>	μm	For high power applications Customer and supplier have to agree on chuck-layout and gravity correction
	Edge Profile Coordinate Cy (see Table A1-5)	116		μm	T/3 Template
	Thickness	500	±25	μm	
Option	n2 <sup>#1</sup>	<u>0</u>	<u>≤75</u>	μm	For high power applications and high frequency applications Customer and supplier have to agree on chuck-layout and gravity correction
	Edge Profile Coordinate C <sub>y</sub> (see Table A1-5)	125		μm	T/4 Template
The TO	Chantar arread to do a	no of the fall			
*No mo	tion is required in this s	tep.	owing action	лі <b>5</b> .	
Δlr	eady addressed by Comm	enter # Com	ment #		
No	further action was taken I	by the TC Cha	apter.		

		Refer to the	Refer to the TF for more consideration.								
1		New Busi	ness								
	х	Editorial C	Chang	je							
	= =	Options for editorial       Case 1: No vote in this section:         To be included and voted on as a group in § VI. Editorial Changes Other than Those Voted on in § V.									
-		change (check one)	x	Case 2: Voted in th Original section nu "FROM" and "TO"	is section: umber and fields.	ne full s	I sentence are required in				
		FROM: T Carbide	able Wafe	A1-9 Dimensional an rs	nd Toleranc	e Characte	ristics o	f 200-mm Silicon			
				Property	Dimension	Tolerance	Units	Note			
Edit		Option 1 <sup>#1</sup>		Thickness GMLYMER (Warp)	<u>500</u> 0	±25 ≤75	μm μm	For high power applications and high frequency applications Customer and supplier have to agree on chuck-layout and gravity correction			
orial Cl	1			Edge Profile Coordinate Cy (see Table A1-5)	125		μm	T/4 Template			
han				Thickness	<mark>350</mark>	±25	μm				
nes		Option 2 <sup>#1</sup>		GMLYMER (Warp)	0	≤85	μm	For high power applications Customer and supplier have to agree on chuck-layout and gravity correction			
				Edge Profile Coordinate Cy (see Table A1-5)	116		μm	T/3 Template			
		#1 Thickness Warp values progress on t #2 It is recon	s option is inter he evo nmend	n 500µm is regarded as the red nded for applications optimize lving market. ed to consider SFQR as an ado	commended optic d for thinner subs litional requireme	on. The option v strates on the co ent by customer	vith thickness st of a highe and supplies	s 350μm in combination with higher r Warp specification, giving room for c.			

Wafers										
	Property	Dimension	Tolerance	Units	Note					
	Thickness	<mark>350</mark>	±25	μm						
Option 1 <sup>#1</sup>	GMLYMER (Warp)	0	≤85	μm	For high power applications Customer and supplier have to agree on chuck-layout and gravity correction					
	Edge Profile Coordinate Cy (see Table A1-5)	116		μm	T/3 Template					
	Thickness	<mark>500</mark>	±25	μm						
Option 2 <sup>#1</sup>	GMLYMER (Warp)	0	≤75	μm	For high power applications and high frequency applications Customer and supplier have to agree on chuck-layout and gravity correction					
	Edge Profile Coordinate Cy (see Table A1-5)	125		μm	T/4 Template					
<ul> <li>#1 Thickness option 500µm is regarded as the recommended option. The option with thickness 350µm in combination with hi Warp values is intended for applications optimized for thinner substrates on the cost of a higher Warp specification, giving room progress on the evolving market.</li> <li>#2 It is recommended to consider SFQR as an additional requirement by customer and supplier.</li> </ul>										
Justifica Editorial. thickness	Justification (If necessary) Editorial. To improve readability. Swap rows to match with previous table A1-8, so that 350 $\mu$ thickness appears before 500 $\mu$ m									
on	To approve abov	e editorial o	change(s)							
on by/2 <sup>nd</sup> by	By: Tom Barbieri Second: Michael	/ Cree, Inc Buchweitz-	-Moenke / Infi	ineon Techr	nologies Austria AG					
ussion	None									
	6-Y 0-N; Motion	passed								

	*TF	/TC Chapter to fill in section/paragraph #, if necessary.
Comment	Tab Pag Del "Ta Car	le of content ge 1 In List of Tables Table A1-6, ete "2 inch and" ble A1-6 Dimensional and Tolerance Characteristics of <del>2 inch and</del> 3-inch Silicon bide Wafers with Secondary Flat"
	The	e TC Chapter agreed to do one of the following actions.
	*No	motion is required in this step.
Inctio		Already addressed by Commenter #, Comment #
ň	x	No further action was taken by the TC Chapter. Should be taken care by publication as table of content will be automatically updated.
		Refer to the TF for more consideration.

	New Business
	Editorial Change

This table is needed for each Comment accompanied a Vote

Table A1 Seconda	-6 Dimensio ry Flat	onal and Tolera	ance Charact	eristics of <mark>2-in</mark>	<mark>ch and</mark> 3-inch	Silicon Carb	olde Wafers with
Nomine	al Diameter	<del>50.8mn</del>	<del>ı (2 inch)</del>	76	5.2mm (3 inch)	12	
Pi	operty	Dimension	<i>Tolerance</i>	Dimension	Tolerance	Units	Note
Diameter		<del>50.8</del>	<del>±0.25</del>	76.2	±0.25	mm	
Primary Fla	at Length	<del>15.8</del>	<del>±1.6</del>	22.0	±2.0	mm	
Secondary	Flat Length	<del>8.0</del>	<del>±1.6</del>	11.0	±1.5	mm	
GMLYME	R (Warp)	θ	≤25	≤25	≤25	μm	
GBIR (Tota Variation)	al Thickness	θ	<u>≤10</u>	<u>≤10</u>	≤15	μm	
SBIR (Loca Variation)	al Thickness	θ	53	≤5	<u>_</u>	μm	
Change	Dimension	ness varial $(<1)$	10n				
Change I SBIR(Lo Change I	Dimension Dimension Dimension	ness Variat n from " $\leq 10$ ness Variat n from " $\leq 5$ '	tion) <del>?</del> " to "0" tion) " to "0" an	d Toleranco	e From " <del>≤5</del>	" to "≤5	"
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Change I SBIR(Lc Change I The TC ( *No moti Alrea No fr Refe New x Edito cha	Dimension Dimension Dimension Chapter age on is required ady addres urther action er to the TF Business prial Change ions prial nge	ness variation from " $\leq 14$ ness Variation from " $\leq 5$ " greed to do nired in this sed by Com on was taken for more co ge Case 1: No To be inclu- than Thos Case 2: Vo	tion) " to "0" tion) " to "0" an one of the step. menter #, ( by the TC onsideration o vote in the uded and v e Voted on oted in this	d Tolerance following a Comment # Chapter.	e From " <del>≤5</del> ctions.	" to "≤5	rial Changes Oth

# FROM: Table A1-6 Dimensional and Tolerance Characteristics of 3-inch Silicon Carbide Wafers with Secondary Flat

Nominal Diameter	76	.2mm (3 inch)		
Property	Dimension	Tolerance	Units	Note
Diameter	76.2	±0.25	mm	
Primary Flat Length	22.0	±2.0	mm	
Secondary Flat Length	11.0	±1.5	mm	
GMLYMER (Warp)	≤25		μm	
GBIR (Total Thickness Variation)		≤15	μm	
SBIR (Local Thickness Variation)	≤5		μm	
Thickness	350	±25	μm	For high power and high frequency applications (HP and HF)
Edge Profile Coordinate C <sub>y</sub> (T/3 template) (see Table A1-5)	126		μm	

#1 Edge Profile Coordinate T/4 Template is not specified.

#### 1

Editorial Changes

#### TO: Table A1-6 Dimensional and Tolerance Characteristics of 3-inch Silicon Carbide Wafers with Secondary Flat

Nominal Diameter	70	5.2mm (3 inch)		
Property	Dimension	Tolerance	Units	Note
Diameter	76.2	±0.25	mm	
Primary Flat Length	22.0	±2.0	mm	
Secondary Flat Length	11.0	±1.5	mm	
GMLYMER (Warp)	<u>≤250</u>	<u>&lt;25</u>	μm	
GBIR (Total Thickness Variation)	<u>0</u>	≤15	μm	
SBIR (Local Thickness Variation)	<u>≤50</u>	<u>&lt;5</u>	μm	
Thickness	350	±25	μm	For high power and hig frequency applications (HP and HF)
Edge Profile Coordinate C <sub>y</sub> (T/3 template) (see Table A1-5)	126		μm	

**Justification (If necessary)** Formatting error. Restore original values. An error was introduced during the ballot preparation. The original table A1-6 shows these values (highlighted in yellow) below. The ballot inadvertently shifted these values.

#### Table A1-6 Dimensional and Tolerance Characteristics of 2-inch and 3-inch Silicon Carbide Wafers with Secondary Flat

Nominal Dia	imeter	50.8mm (2	inch)	76.2mm	(3 inch)					
Prope	erty	Dimension	Tolerance	Dimension	Tolerance	Units	Note			
Diameter		50.8	±0.25	76.2	±0.25	mm				
Primary Flat Le	ength	15.8	±1.6	22.0	±2.0	mm				
Secondary Flat	Length	8.0	±1.6	11.0	±1.5	mm				
GMLYMER (V	Varp)	0	≤25	<mark>0</mark>	<mark>≤25</mark>	μm				
GBIR (Total Th Variation)	nickness	0	≤10	<mark>0</mark>	<mark>≤15</mark>	μm				
SBIR (Local Th Variation)	nickness	0	≤5	0	<mark>≤5</mark>	μm				
Thickness		250	±25	N/A	N/A	μm	For opto- electronic applicatio (OP)			
		380	±25	350	±25	μm	For high power an high frequence application (HP and HF)			
Edge Profile Co (T/3 template)	oordinate C <sub>y</sub> (see Table	83		83		μm	For 250 p thickness			
A1-5)	`	126		126		μm	For 380 µ thickness			
#2 Edge Profile	Coordinate T/4	Template is not specifie	ed.							
otion	To approv	ve above editorial	change(s)							
otion by/2 <sup>nd</sup> by	By: Tom Second:	y: Tom Barbieri / Cree, Inc. econd: Hans Christian Alt / Munich University								
iscussion	None									
ote	6-Y 0-N; I	Motion passed.								

	*TFA Pag	<b>TC Chapter</b> e 17 In Tab	to le /	fill in section/paragrap A1-12	h #, if necessary.								
Comr	Pag	· · · · · · · · · · · · · · · · · · ·		Conductive wafers See Table A1-2 for po	ssible applications	SEMI MF673 <sup>#4</sup>							
nent	tigh-resistivity or semi-insulating material ee Table A1-2 for possible applications												
	As noted above, some characters in the table are missing.												
	The	e TC Chapte	r ag	greed to do one of the	following actions								
	*No motion is required in this step.												
Þ	Already addressed by Commenter #, Comment #												
tion		No further a	actio	on was taken by the TC	Chapter.								
Γ		Refer to the TF for more consideration.											
		New Business											
	х	Editorial Ch	ang	je									
		Options		Case 1: No vote in this section:									
		for		then Those Voted on in § V.									
		change		Case 2: Voted in this	section:								
		(check one)	x	Original section num "FROM" and "TO" fie	one full sentence are re	equired in							
		FROM: Table A1-12	Те	st Methods for SiC Wafer	Specification and (	Order Entry							
				Resistivity*	Conductive wafers See Table A1-2 for possible applications								
Edit					ligh-resistivity or semi-insulating material ee Table A1-2 for possible applications								
orial		TO:											
Cha	1	Table A1-12	Tes	st Methods for SiC Wafer	Specification and	Order Entry							
nges					Conductive wafers See Table A1-2 for	possible applications							
				Resistivity*	High-resistivity or See Table A1-2 for	semi-insulating material							
		luctificati	0.0	(If pagagary)		possible approactions							
		Editorial.	For	matting error.									
М	otion	l	Т	o approve above editori	al change(s)								
м	otion	by/2 <sup>nd</sup> by	E S	By: Tom Barbieri / Cree Second: Christian Krane	, Inc. ert / Fraunhofer IIS	SB							
D	iscus	sion	N	lone									
V	ote		6	-Y 0-N; Motion passed.									





# V-(ii) Comments Created by Handling Negative None

# VI. Editorial Changes Other than Those Voted on in § V

Original section/paragraph number and at least one full sentence are required in "FROM" and "TO" fields.

None other than above.

# **VII. Approval Conditions Check**

# VII. - (i). Approval Rate

APPROVAL CONDITION 1: All Negatives have been discussed and were withdrawn, found not related, found not persuasive, or addressed by a technical change. (*Regulations* ¶ 9.6.2.1.2)

APPROVAL CONDITION 2: At least 90% of the sum of valid Voting Interest Accept and Voting Interest Reject Votes must be Accept. (*Regulations* ¶ 9.6.2.1.3)

Note: If both approval conditions are not satisfied, the Document fails.

		Accepts		(Accepts + Valid Rejects)			
Approval Rate	=	60	/	60	=	100.0%	≥90%

## VII. – (ii) Approval Level (check one)

Note: See Regulations § 9.6.2 for further information.

**Globally Approved (No Ratification Ballot needed):** The Letter Ballot meets the Letter Ballot approval conditions for the global technical committee.

### **Need a Ratification Ballot:**

The Letter Ballot meets the Letter Ballot approval conditions for the TC Chapter and a Ratification Ballot will be issued to validate technical changes.

# **VIII. Safety Check**

X

#### Note: See Regulations § 15 for further information.

	x	Th is	i <b>is is not a</b> still technica	<b>Safety Document</b> , when all safety-related information is removed, the Document lly sound and complete. ( <i>Regulations</i> ¶ 8.7.1)							
<b>This is a Safety Document</b> , when all safety-related information is removed, the Document is rechnically sound and complete. ( <i>Regulations</i> ¶ 8.7.2)											
			Safety Che throughout	list ( <i>Regulations</i> ¶ 15.3) is complete and has been included with the Document e balloting process. ( <i>Regulations</i> ¶ 15.1.2)							
	Motion by/2 <sup>nd</sup> by			By: Tom Barbieri / Cree, Inc. Second: Christian Kranert / Fraunhofer IISB							
	Discussion			None							
Vote 6-Y 0-N; Motion passed				6-Y 0-N; Motion passed							

# IX. Intellectual Property (IP) Check

Note: This Letter Ballot may cover all or part of a Standard or Safety Guideline. Regardless of the coverage, this IP check applies to the entire Standard or Safety Guideline\*. See *Regulations* § 16 for further information.

x	The TC Chapter meeting chair asked those participating, if they were aware of any patented technology that might be relevant (see <i>Regulations</i> ¶ 16.3.1.1) to the Standard or Safety Guideline; or, any copyrighted items or trademarks that are used/reproduced (see <i>Regulations</i> ¶ 16.4.1.2) in the Standard or Safety Guideline. (Also see, <i>Regulations</i> § 8.8)						
	×	The question is NOT answered in affirmative (No potentially material patented technology or use/reproduction of copyrighted items/trademarks is known.)	GO TO SECTION X.				
		The question is answered in affirmative	ls any of the known IPs a patented		Yes, at least one of them is a patented technology	GO TO IX (a) "Patented Technology" subsection	
			technology?		No	GO TO IX (b) "Copyright items" subsection	

### IX(a) Patented Technologies subsection

#### IX(a1) Total numbers of Patented Technologies to be dealt with

# Fill	<b>(I)</b> Known Patented Technology that might be relevant to	# Fill number	( <b>m</b> ) Number of patented technologies first became known to the TC Chapter on or after the day of the issuance of this Letter Ballot	Postpone assessment of such patented technologies to be performed at the next scheduled TC Chapter meeting.
number	the Standard/Safety Guideline	# Fill number	(n) Number of patented technologies first became known to the TC Chapter before the day of the issuance of this Letter Ballot	GO TO IX (a2)

#### IX(a2) Assessment of disclosed patented technologies

Disclosed patented technology #1 ( <i>Brief description, e.g., patent title and numbe</i>				Date of Asse Letter Ballot MM/DD/YYY	ssmo <mark>adju</mark> Y	ent (If diff dication)	erent from the date of
Is disclosed patented		YES (It is a PMPT)	ls the us PMPT te	se of this echnically		YES	PROCEED to assess NEXT one, or if this is the last one, GO TO IX(a3)
"might be material" to the Standard/Safety Guideline?		justified	?		NO	The Document is failed and returned to the TF	
		NO	No furth	er action is nee	ded f	or patente	d technology #1

This table is needed for each disclosed patented technology.

(ab) LOA Status check			/I VVII		inclusion asse	essed to be justified			
LOA Status of PMPT #1									
		YES	PR or i	PROCEED to check NEXT one, or if this is the last one, GO TO IX(b)					
Has an LOA for this patented technology been received from every owner?		NO	MO		Ask ISC for sp	ecial permission to publish.			
			DTION		Quit activity.	The Document is failed and returned to the TF			
					Wait for LOA	PROCEED to check NEXT one, or if this is the last one, GO TO IX(b1)			
			Mo	tion	by/ 2 <sup>nd</sup> by	Name (Company)/Name (Company)			
			Dis	cuss	sion	XXXX			
			Vot	e		XX Y-XX N; Motion passed (or failed)			

#### IX(a3) LOA status check of PMPT of which inclusion assessed to be justified

This table is needed for each PMPT of which inclusion assessed to be justified.

#### IX(b1) Total numbers of copyrighted items to be dealt with

# Fill	(o) Known copyrighted items that are used or reproduced to the	o > 0 There is at least one known copy righted items that might be relevant to the Standard/Safety Guideline	GO TO IX (b2)
number	Standard/Safety Guideline	o <b>= 0</b> There is no disclosed copyrighted item	GO TO IX (c)

#### IX(b2) Assessment of disclosed copyrighted items

Disclosed copyrighted item (Brief description of its use	#1 <i>in th</i>	e Documei	nt):			
Is disclosed copyrighted		YES	Is the use/reproduction of this copyrighted item technically justified?		YES	PROCEED to assess NEXT one, or if this is the last one, GO TO IX(b3)
in the Standard/Safety Guideline?					NO	The Document is failed and returned to the TF
		NO	No further action is nee	ded f	or copyrig	hted item #1

This table is needed for each disclosed copyrighted item.

# IX(b3) Copyright release status check of copyrighted item of which inclusion assessed to be justified

Copyright release Status of copyrighted item #1						
		YES	PROCEED to assess NEXT one, or if this is the last one, GO TO IX(c)			

Has the copyright release been received		NO	MOTION		Ask ISC for special permission to publish.		
					Quit activity.	The Document is failed and returned to the TF	
from its owner ?.					Wait for copyright release letter	PROCEED to check NEXT one, or if this is the last one, GO TO IX(c)	
				tion	by/ 2 <sup>nd</sup> by	Name (Company)/Name (Company)	
				cuss	sion	XXXX	
				e		XX Y-XX N; Motion passed (or failed)	

This table is needed for each copyrighted item of which use/reproduction assessed to be justified.

#### IX(c) Assessment of disclosed (identified) trademark

Is there any trademark in the Standard/Safety Guideline?	YES	Is every instance of trademark use technically justified?		YES	GO TO IX(d)
				NO	The Document is failed and returned to the TF
	NO	GO TO IX(d)			

### IX(d) IP check completion condition check

The co-chair checks if any Patented Technologies first become known to the TC Chapter on or after the day of the issuance of this Letter Ballot? i.e., m>0 in IX(a1)	YES	Sections IX(a2) and IX(a3) shall be completed and recorded for such patented technologies at next scheduled meeting of the TC Chapter. Until then, the TC Chapter shall NOT go to X (making motion to pass/fail this Document) (see <i>Regulations</i> ¶ 16.4.1.2) Until then this Letter Ballot Review is on hold.
	NO	GO TO X

# X. Action for This Document

Motion		This Docur SC for proc	ment passed TC Chapter review as balloted and will be forwarded to the ISC A&F cedural review.						
	x	This Docur ISC A&R S	his Document passed TC Chapter review with editorial changes and will be forwarded to the SC A&R SC for procedural review.						
		This Docur editorial ch Ratificatior	cument passed TC Chapter review with technical changes and with or without I changes and will be forwarded to the ISC A&R SC for procedural review. A tion Ballot will be issued to verify the technical changes.						
		This Docur	ment failed TC Chapter review and will be returned to the TF for rework.						
		This Document failed TC Chapter review and work will be discontinued.							
Motion by/ 2 <sup>nd</sup> by		By: Tom Barbieri / Cree, Inc. Second: Christian Kranert / Fraunhofer IISB							
Discussion			None						
Vote			6-\	6-Y 0-N					
Final Action		x	Motion passed						
			Motion failed						

Note: If the use of PMPT or copyrighted item is justified by the TC Chapter, LOA or release form must be received before publication can proceed.